Substrate Dependence in the Formation of Au Nanoislands for Plasmonic Platform Application

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Abstract

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In this work, the influence of the various substrates on Au nanoisland formation has been studied. Nanostructures were obtained via annealing of thin Au films. In order to determine nanoisland formation mechanisms, correlation between an initial film thickness and temperature of formation, shapes, and dimensions of nanostructures was examined. For the surface morphology studies, nanograin structure, and chemical composition analysis, SEM, HR TEM, and EDS measurements were performed, respectively. Morphology studies showed that the temperature at which nanostructures form varies for different substrates, which indicates high impact of the substrate material on the nanostructure formation. In the case of silicon substrate, besides the phenomenon of spinodal dewetting, the effect of eutectics on the nanostructures was additionally taken into consideration.

Keywords Directional solidification \cdot High-resolution electron microscopy (HREM) \cdot Nanostructure \cdot Scanning electron microscopy (SEM) \cdot Thin-film annealing

Introduction

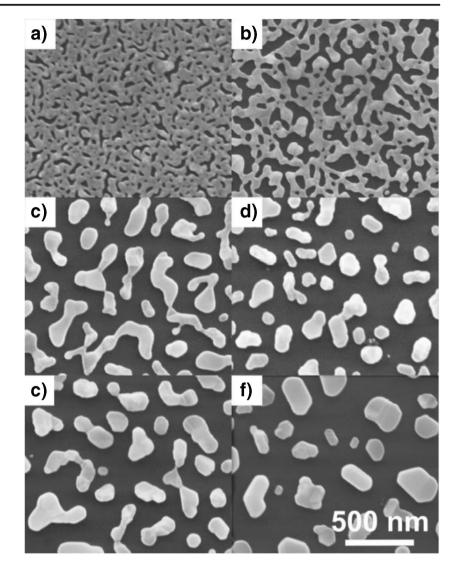
In recent years, much attention has been paid to the formation of noble metal nanostructures. This is mainly due to the possibility of using them as plasmonic platforms and nanosensors [1, 2]. One of the most commonly used metals in plasmonic platforms is gold. In addition to the high concentration of free electrons, leading to a high plasma frequency and a negative real permittivity over a wide range of frequencies, gold is characterized by high chemical resistance, which greatly facilitates the process of producing platforms [3]. The frequency and intensity of the plasmon resonance are highly dependent not only on the material of the nanostructures but also on its size, shape, and morphology. There is also a strong correlation

Marcin Łapiński marcin.lapinski@pg.edu.pl with dielectric properties of surrounding medium [4-6]. One of the easiest methods for the production of metal nanostructures is the way that is based on the thermal annealing of thin metal films [7, 8]. It is well known that several processes could be responsible for the formation of the nanostructures within this technique. One of them is directional solidification of eutectics that is widely cited in the literature. It may occur in the case of the gold film that is deposited on a silicon substrate. The melting temperature of Au-Si eutectic system drops to about 363 °C [9–12], so nanostructures can be formed in the temperatures much below the melting temperature of Au. However, it can lead to phase non-homogeneity of the gold nanostructures [10, 12–15]. On the other hand, in the cases of thin and ultra-thin layers, the leading process of nanostructure growths seems to be solid-state dewetting. It is widely discussed in the literature that the formation of nanostructures is based on nucleation of holes and their later growth [2, 16–19]. Nucleation can take place in two ways: as homogeneous nucleation, when holes appear as a consequence of small thermal density fluctuations. The second type is a heterogeneous nucleation, caused mainly by defects present or in the metal film or on the interface between the film and the substrate. Holes can be also created during the spinodal dewetting process, which occurs by the amplification of

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Fig. 1 SEM images of gold nanostructures on silicon substrate, with initial gold film of 10 nm, annealed at a 300 °C, b 325 °C, c 350 °C, d 375 °C, e 400 °C, and f 425 °C



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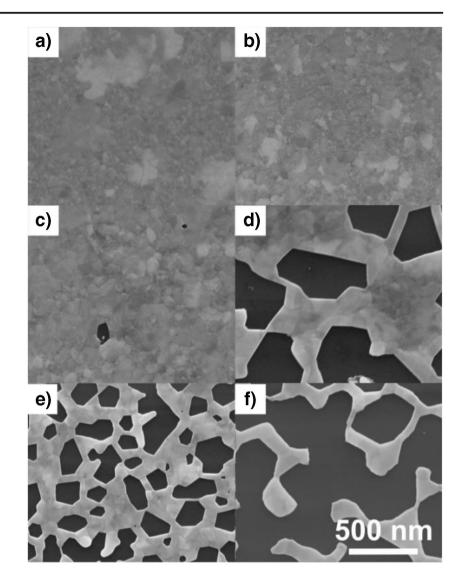
periodical film thickness fluctuation. In any case, dewetting occurs at temperatures well below the melting temperature of the film, so during this process the material remains in the solid state. It is difficult to determine experimentally which of the types of dewetting takes place in a specific case in the process of formation of metal nanostructures. Undoubtedly, the substrate plays a huge role here. It is also difficult to say whether the existence of eutectics has a significant impact on the formation of nanostructures at temperatures above the eutectic temperature, especially that the size of nanostructures or thin films greatly affects their melting point [20, 21].

In our previous works [22, 23], we described the method of synthesis, structure, and electromagnetic field distribution of Au nanostructures that form plasmonic platforms. However, at that time, we could not decide which process was mainly responsible for the growth of nanostructures. Present research are focused on processes leading to the formation of nanostructures as a result of heating thin layers deposited on various substrates when the annealing temperature far exceeds the temperature at which dewetting starts.

Experimental

Au nanostructures were prepared on quartz glass, Si(111), and well-polished Mo and Ta substrates. The substrates were cleaned with warm acetylacetone and then rinsed in ethanol. Thin Au films (with thickness in the range of 1–200 nm) were deposited using a tabletop dc magnetron sputtering coater (EM SCD 500, Leica) in pure Ar plasma condition (argon,

Fig. 2 SEM images of gold nanostructures on tantalum substrate, with initial gold film of 10 nm, annealed at a 300 °C, b 325 °C, c 350 °C, d 375 °C, e 400 °C, and f 425 °C



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Air Products, 99.999%). The Au target had 99.99% purity, the rate of Au layer deposition was about 0.4 nm/s, and incident power was in a range of 30–40 W. The sputtering system was equipped with a quartz crystal microbalance for the film thickness in situ measurements. As prepared films of varying thicknesses were subsequently put to the hot furnace for formation of nanostructures. Samples were annealed at various temperatures in air atmosphere. To analyze the surface morphology of the samples, FEI Quanta FEG 250 scanning electron microscope (SEM) and Zeiss CrossBeam 540 SEM operated at 10 kV and 2 kV, respectively, were used. For nanograin structure and chemical composition analyses, a TALOS F200X high-resolution transmission electron microscope (HR TEM) equipped with an EDS detector was used.

Results and Discussion

In Figs. 1 and 2, selected SEM images of nanostructures formed during annealing of 10-nm thin Au films at different temperatures are presented. The films were deposited on silicon (Fig. 1) and tantalum (Fig. 2) substrates. The heating temperature's as well as the substrate's influence on the formation of nanostructures is well visible. However, in both cases, the process of formation of nanostructures begins with ruptures in the layer. Then, holes are growing, initially irregular-shaped Au structures are formed, and finally, when the temperature increases, separated nanostructures are formed. The process looks similar for both substrates, but the temperature at which the nanostructures form is different. This indicates a high impact of the substrate material on the formation of nanostructures.

The influence of the initial Au film thickness on the temperature of formation of nanostructures on various substrates is shown in Fig. 3. The temperature of nanostructure formation was determined on the basis of SEM images. It was assumed that it is the temperature at which isolated islands are already completely formed, as is shown in Fig. 1d. Regardless of the type of substrate, the fastest temperature rise can be observed for very thin layers, with a thickness of up to 20 nm. In the case of larger thicknesses of the initial layers, the impact on the temperature of formation of nanostructures is smaller. The main force leading to the nanostructures formation is the reduction of the surface energy. This process can be explained on the basis of the phenomenon of dewetting. It takes place well below the melting temperature of the given metal from which the layer is made and leads to formation of separated objects, like droplets, stripes, and pillars [24]. It can be concluded from the presented SEM images (Figs. 1 and 2) that in the case of the examined films, the phenomenon of spinodal dewetting is mainly responsible for nanostructure growth. In this process, ruptures in the layer appear spontaneously due to thermally activated surface waves. When the size of the holes reaches the critical size, the edges of holes start to be retracted; and in this way, nanostructures are formed, which was described in detail by Thompson [25]. We suggested in our previous works that this phenomenon can be mainly responsible for Au nanostructure growth on Si and quartz glass supports [22, 23]. Of course, the impact of defects cannot be neglected either in the layer itself or on the interface between the layer and the substrate (heterogeneous dewetting) [25], especially when the substrate and the layer are created by various materials, with different crystalline structures. If nanoislands are formed as a result of spinodal dewetting, then the following relationship can be proposed between the thickness of the layer (h) and the diameter of the nanostructure (D) [26]:

$$D = \left(\frac{24\pi^{3}\gamma}{Af(\theta)}\right)^{1/3} h^{5/3} = Ch^{5/3}$$

where $f(\theta)$ is the geometric factor based on the particle contact angle θ , γ is the surface tension of the metal, and A is the Hamaker constant. This relation was observed in many experimental studies [26, 27] and remains valid at the temperature at which the isolated islands appeared. However, very often, in order to obtain the optimal shape and size of nanostructures, the nanostructures are formed at much higher temperatures. The films, for whom the calculations of parameters are described by the above equation, were deposited on silicon substrate and annealed at 550 °C for 15 min. Thermal conditions were chosen because of the plasmon resonance parameters of manufactured plasmonic platforms, which was studied in our previous works [22, 23]. The dependence of the island's diameter on the thickness of the initial layer for these conditions is presented in Fig. 4. In this case, the calculated exponent is equal to 2.60 ± 0.02 and significantly deviates from the value characteristic for spinodal dewetting. However, we are here far beyond the

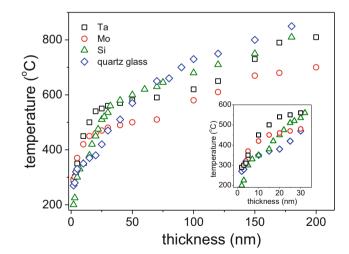


Fig. 3 The influence of film thickness on the temperature of formation of nanostructures. The smallest thickness of the layer from which the studies were started is 2 nm

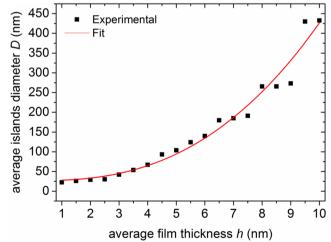
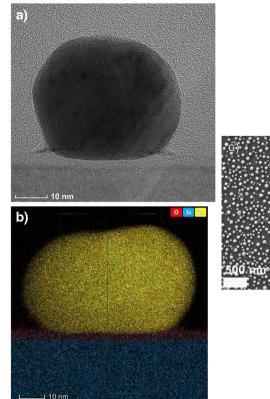
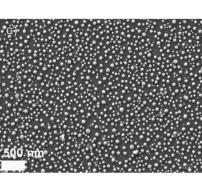


Fig. 4 The dependence of the island's diameter on the thickness of the initial film, calculated for Au films deposited on the silicon substrate. The films were annealed at 550 $^{\circ}$ C for 15 min

Fig. 5 a HR TEM image of 2.8nm thin film, annealed at 550 °C for 15 min. **b** EDS analysis of the nanograin. **c** SEM image of the sample





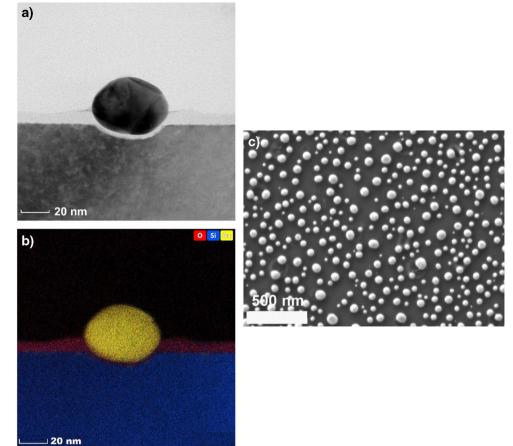
range in which nanostructures have already formed. It is also well above the eutectic temperature, which in the Au– Si system is around 363 °C [9–12]. Au–Si forms one of the simplest eutectic alloy; therefore, during cooling below the eutectic temperature, Au and Si crystallize into two different phases. As a result of that mechanism, heterogeneous nanostructures of Au containing Si phase inclusions are formed. Such nanostructures have been observed in several works describing directional solidification of Au–Si eutectics [10, 13, 14, 28].

To explain the effect of eutectic on the formation of Au nanostructures on the Si substrate, HR TEM studies were carried out. The result for the sample annealed at 550 °C for 15 min is shown in Fig. 5. The initial film thickness was equal to 2.8 nm. For clarity, the SEM image of the sample was added (Fig. 5c). As may be seen from EDS analysis, the nanograins are formed only by Au (Fig. 5b). It should be noted, however, that the annealing time is short in this case, which prevents the diffusion of Au by the native SiO₂ layer and hence the formation of eutectics. b

The HR TEM image of a cross section of a nanoisland formed as a result of the heating of the Au layer of the same thickness for 60 min (Fig. 6) is completely different from that shown in Fig. 5. As can be seen, the silicon substrate under the nanograin has been melted. At annealing temperature of about 550 °C, this can be only explained by the fact that as a result of Au to Si diffusion, eutectics between Au and Si was formed. Detailed EDS analysis of a cross section of a nanoisland annealed at 550 °C for 15 min and 550 °C for 60 min is shown in Fig. 7. It may be seen from Figs. 6b and 7b that no Si inclusions are visible in the Au nanostructure. On the other hand, such a situation as where a whole structure is made entirely of metal can take place in nanosized scale [29]. As shown in the presented HR TEM images, in the case of growth of nanostructures by thin-layer annealing, the substrate plays a huge role. This should be taken into account especially when looking for optimal structures for applications, e.g., in plasmonic platforms.

Conclusions

This paper presents the formation of Au nanostructures on various substrates, like quartz glass, Si, Mo, and Ta. Nanostructures were grown as a result of annealing of thin Au films, with thicknesses in the range from 1 up to 200 nm. **Fig. 6** a HR TEM image of 2.8nm thin film, annealed at 550 °C for 60 min. **b** EDS analysis of the nanograin. **c** SEM image of the sample



In the case of silicon substrate, the effect of eutectics on the growth of nanostructures was analyzed. As may be concluded from HR TEM results, when the annealing occurs at temperatures higher than the temperature of eutectics, besides the phenomenon of solid-state dewetting, directional solidification of eutectics should be also considered in the process of nanostructure formation, especially in the case of a long annealing time when the atoms of metals have

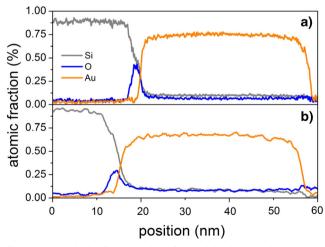


Fig. 7 EDS analysis of cross section of a nanoisland annealed at a 550 $^{\circ}{\rm C}$ for 10 min and b 550 $^{\circ}{\rm C}$ for 60 min

enough time for diffusion into the substrate. It should also be emphasized that in the case of thin layers, the melting point of the material is reduced in relation to the bulk material. Certainly, in the annealing process, at temperatures higher than characteristic for the phenomenon of dewetting, it will affect the shape and size of the nanostructures.

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